# Patent indicators for the Spanish Nanotechnology domain

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This poster presents the indicators of a patentometric study of Spanish nanotechnology [1] that was presented in a Nanotech Event [2]. The analysis was conducted for the years 2004 to 2014 and the search strategy was based on keywords of a established query [3] and relevant patent classifications. As a patent data source the database *Espacenet-Worldwide* from the European Patent Office was used since a previous study from the authors showed that it provided the best data coverage for the purpose of the study [4]. More than 3400 patent records with Spanish authorship were retrieved and after an exhaustive data harmonization process a patentometric analysis was performed using the software tool Matheo Patent. For a patent/paper comparison furthermore scientific article data was retrieved from *Scopus*. Subsequently several indicators were generated which we grouped into the following types: *Performance Indicators, Technology network indicators, Collaboration indicators and Patent value indicators*.

# Spain vs. World

Spain's voira Spanish patenting in Nanotechnology was compared to worldwide patenting and publishing. By launching the search query to the total worldwide database and to applicant affiliations of seven important Nano output countries we could see how the Spanish nanotechnology is behaving compared to an international basis. Two types of countries could be identified (see Figure 1): On the one hand a group comprising the United States, Ja-pan and South Korea where the production of patents is relatively higher than the scientific production. On the other hand a group with the opposite behaviour, which includes especially China and to a lesser extent the UK and Spain. Spain intervenes at 1% of the patents on nanotechnology in the world, but has more than double the representation for scientific papers.



#### Thematic profile

Regarding the Spanish Nanotechnology thematic profile we compared it with worldwide patenting and could tagenting and paperation indirectionality intensite processing and the second s



#### Publications per patent office

By identifying the patent authorities where the appli cants file their patents we can see which countries or patent systems were considered of interest for the appatent systems were considered of interest for the ap-plicant to protect their invention. As expected from pat-ents with Spanish authorship most patents were filed at the Spanish patent office (ES), but closely followed by filings of PCT applications (WO) at the World Intellectual Property Organization. The third and fourth most im-portant patent filing destination was the US and the European Patent Office (EP). It is interesting to see that China, seems to have overtaken Japan as a more desira-ble patenting destination for Spanish nanotechnology.



### Country collaboration

Regarding the co-authorship of inventors from Spain with inventors from other countries most col--your more inventors inom other countries most col-laboration in nanotechnology patents is done with inventors from the US, followed by Germany, Great Britain and France as can be observed in the follow-ing network map.





If we analyze the patent output according to its appli-cant's sector affiliation the universities are prevalent (37%), followed by private enterprises (24%), the CSIC (20%) and other research centres (16%).



#### Patent inter tion ratio

In order to measure the effort of internationalization we describe an indica

In order to measure the effort of internationalization we describe an indica-tor, which is a ratio between the number of patent registrations (in different offices) and patent families (the invention or innovation itself) and can be used to measure the value of patents. When we analyze the rate of internationalization in Spain, we find that the highest values are presented by the companies, whose business model is based on the protection of such innovations and therefore are willing to such an effort. Some universities appear to have higher capacity of internationali-zation than the CSIC centres. The institutions which really stand out are the Universidad de Sevilla and the Universidade de Santiago de Compostela. Both base such a nositive production behaviour tha 5 further study of their techhave such a positive productive behaviour that a further study of their tech-nology transfer offices (TTO) would be of interest.

## Top patenting regions & sectors

Five focal points of nanotechnology patent generation in Spain could be detected with Barcelona and Madrid leading, followed by Valencia. Sevilla and La Coruña.



Applicants (All sectors)	Patent	Patent	Patent IR
	families	records	(records/family)
Salvat Lab SA	1	20	20
Grifols SA	2	35	17,5
Interquim SA	1	14	14
Silicalia SL	2	26	13
Dendrico SL	1	13	13
Tcd Pharma SL	1	13	13
Nylstar SA	1	12	12
Hospital De La Santa Creu I Sant Pau	1	11	11
Hospital Universitari Germans Trias I Pujol	1	11	11
Tolsa SA	1	11	11
Advancell SA	10	104	10,4
Biolan Microbiosensores SL	1	10	10
Histocell SI	1	10	10



The most inventive applicant was the The most inventive applicant was the CSIC research centre Instituto de Ciencia de Materiales de Madrid (ICMM), fol-lowed by the Universidade de Santiago de Compostela and the Universidad de Sevilla. Their inventive strength is an im-portant factor why their correspondent Spanish regions are amongst the top.



# Patent output vs. scientific paper o

It was of interest to compare the patenting and scientific publishing behaviour in order to see some kind of correlation. The top applicants, the Spanish universities of Santiago de Compostela (USC) and Seville (US) in the right side, followed with some distance from the Universidad Politecnica de Valencia (UPV). Although the USC has the highest patent output, it has a moderate paper output comparing to the duter universities (in red). The most productive entity in both, patent families and papers is the Instituto de Ciencia de Materiales de Madrid (ICMM). The most productive in paper publishing turned out to be the two universities of Barcelona (UB and UAB), although the latter have far less patents compared to the ICMM. Non university and CSIC research centres which we can point out is the Institució Catalana de Recerca i Estudis Avançats (ICREA) with a relatively high patent and paper output.



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